

Fig 1: Polarisation-voltage hysteresis for 3D and 2D capacitors.

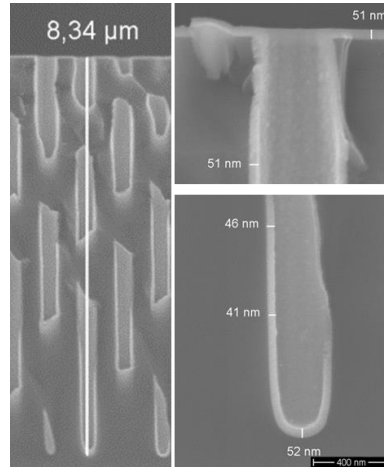


Fig 2: Step coverage of Si:HfO₂ applied for the formation of AFE capacitors.